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Substitute of Paragraphy				re required to respond to a collection of information unless it contains a valid OMB control number. Complete if Known			
	405			Application Number	10/804,430		
INFORMATION DISCLOSURE				Filing Date	03/19/2004		
STA	STATEMENT BY APPLICANT			First Named Inventor	KIM ET AL.		
(Use as many sheets as necessary)				Art Unit	1765		
			ecessary)	Examiner Name	NORTON, NADINE G.		
Sheet	1	of	1	Attorney Docket Number	LMRX-P032 / P1205		

Examiner	Cite	NON PATENT LITERATURE DOCUMENTS Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of	Γ
Initials*	No.1	the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T
LV	1	LEI et al., "The Effect of Ash Processes on Inorganic Porous Low-k Materials," Honeywell Electronic Materials, 4 pp.	
LV	2	COLLINS et al., "Chapter 1: Plasmas for Fun and Profit: A Survey of an Enabling Technology," 1999, pp. 1-24.	
LV	3	COLLINS et al., "Chapter 3: The Wax and Wane of Plasma Technology in IC Manufacturing," 1999, pp. 1-30.	
LV	4	GUERRA et al., "Implementation of Plasma Processing into BEOL with Organic Low-k Dielectrics," 2002 Semiconductor Equipment and Materials International, 5 pp.	
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention

Methods for the optimization of substrate etching in a plasma processing system

Application Number:

10/804430

Confirmation Number:

7228

First Named Applicant:

Jisoo Kim

Attorney Docket Number:

LMRX-P032/P1205

Art Unit:

1765

Examiner:

Nadine G Norton

Search string:

(6518174).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
Ti/	1	6518174	2003-02-11	Annapragada, et			
				al.			

Signature

Examiner Name	Date		
LAN VINH	3/2/06		